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(54) **PLASMA DISPLAY PANEL AND METHOD FOR FABRICATING THE SAME**

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(52) **U.S. Cl.** **313/581**; 313/495; 445/24; 445/25

(58) **Field of Search** 313/581-587, 313/495-497, 605, 634; 445/24, 25; 156/106

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(57) **ABSTRACT**

A plasma display panel and a method for fabricating the same are disclosed, in which the fabricating process time of the plasma display panel can be reduced, characteristic and performance of the panel can be prevented from being reduced, and the panel can be prevented from being damaged. Also, a panel structure is not changed by external pressure variation. The method for fabricating a plasma display panel includes the steps of: depositing a first adhesive along a predetermined area outside an active picture of a first substrate; depositing a second adhesive outside a portion where the first adhesive is deposited, to have a predetermined interval from the first adhesive; depositing a sealant to align with upper portions of the first and second adhesives; depositing an adhesive outside a portion where the second adhesive is deposited, to have a predetermined interval from the second adhesive; aligning a second substrate on the first substrate; and attaching the first and second substrates to each other under a predetermined pressure.

10 Claims, 7 Drawing Sheets

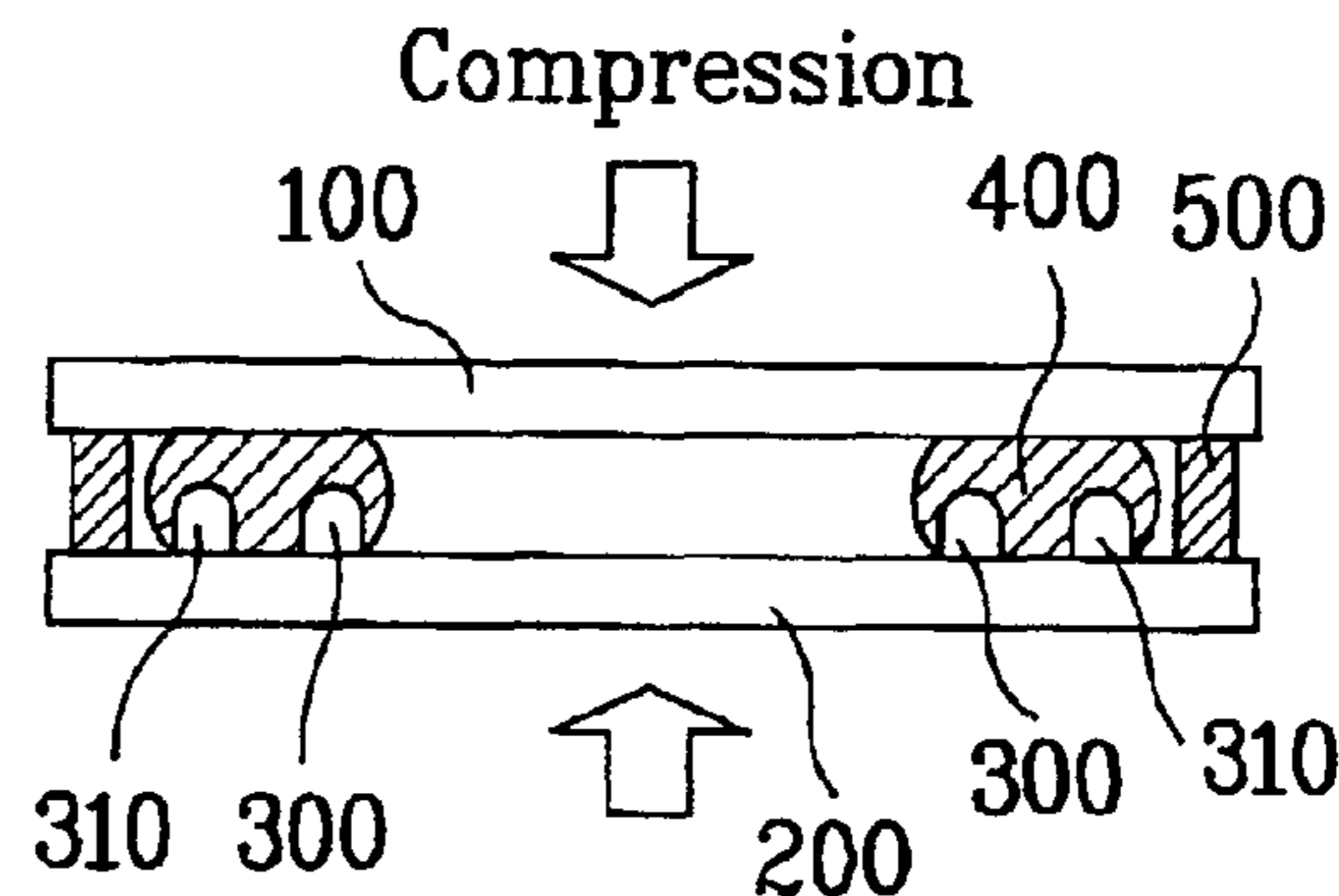
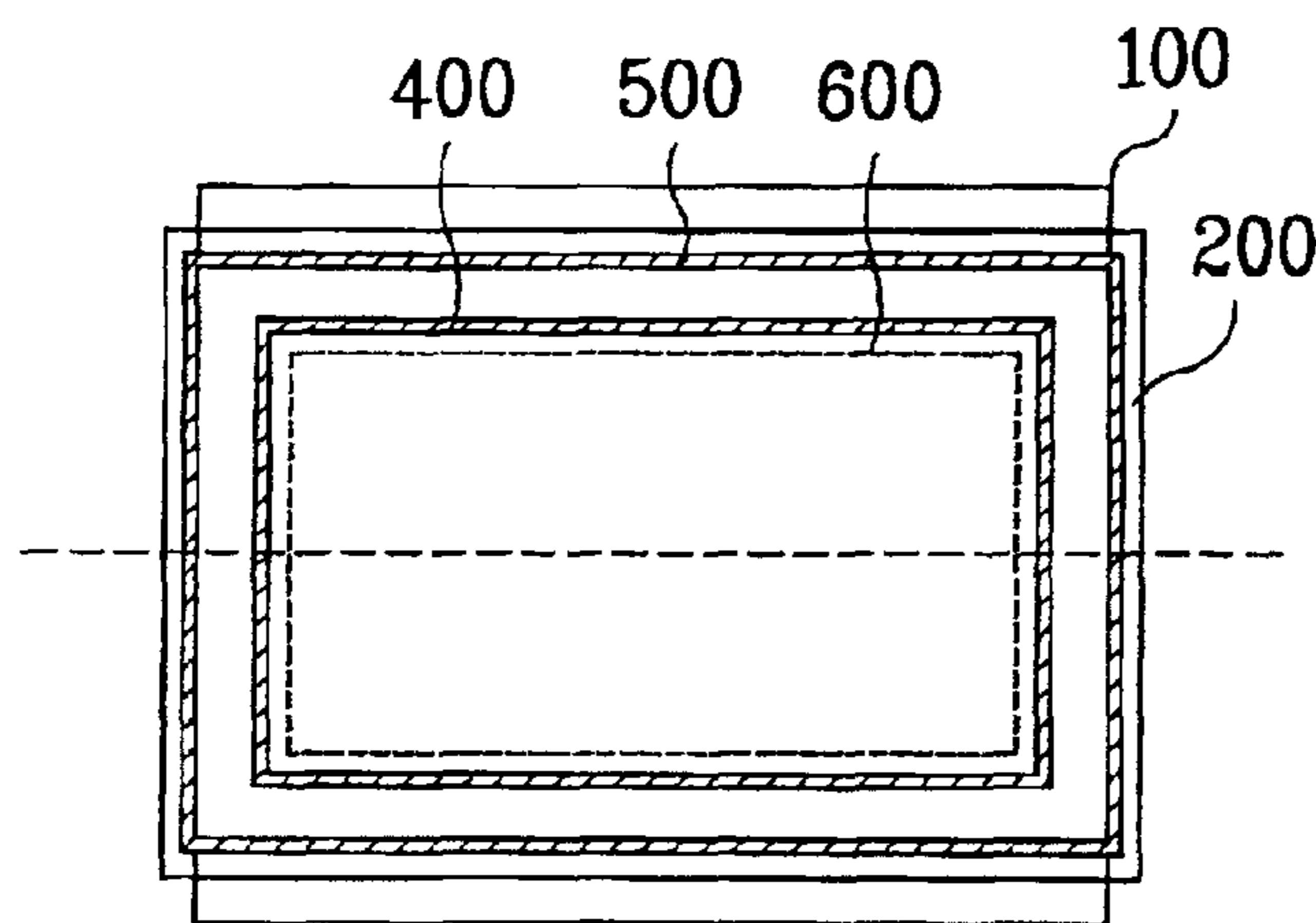


FIG.1A
Related Art

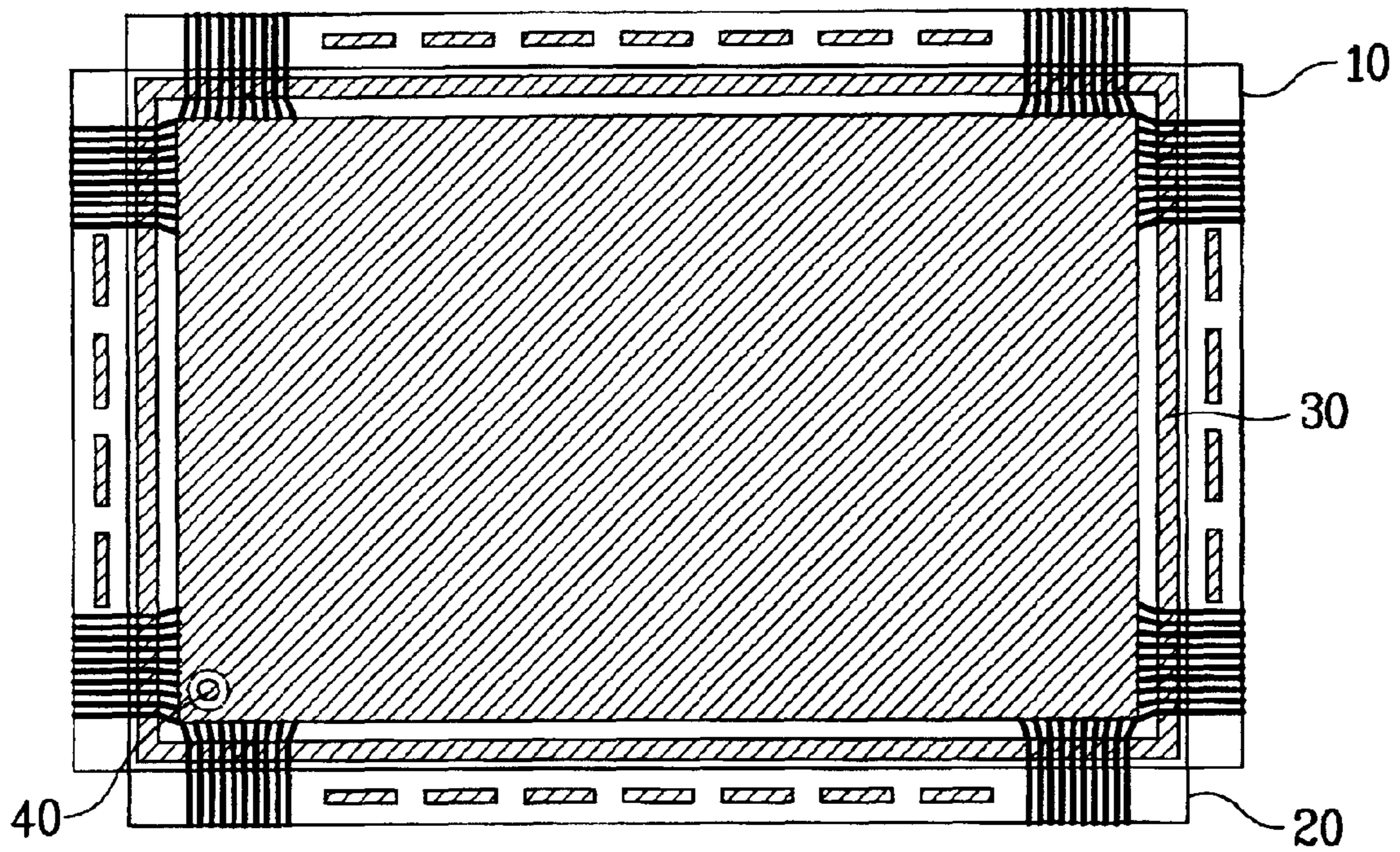


FIG.1B
Related Art

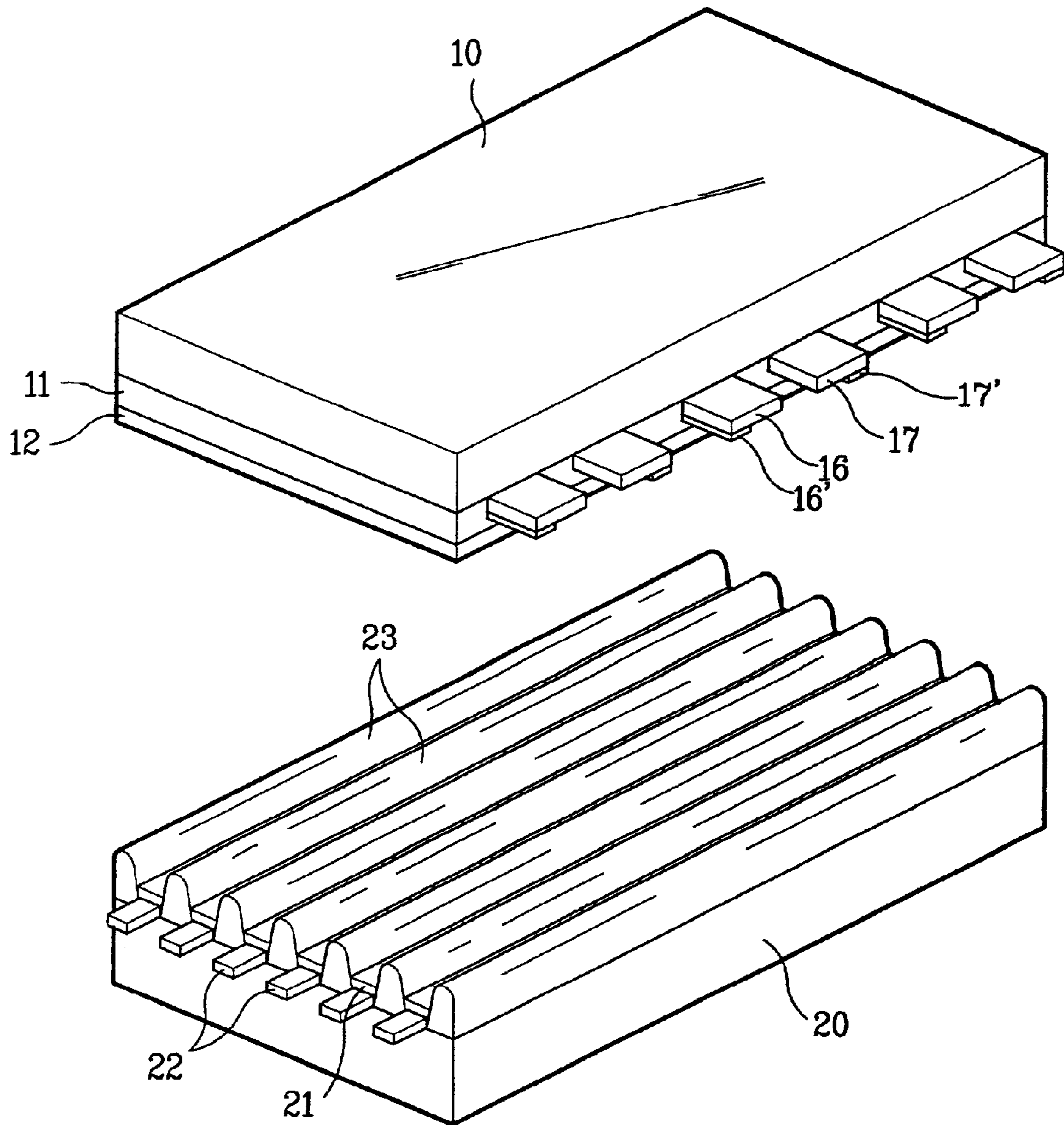


FIG. 1C
Related Art

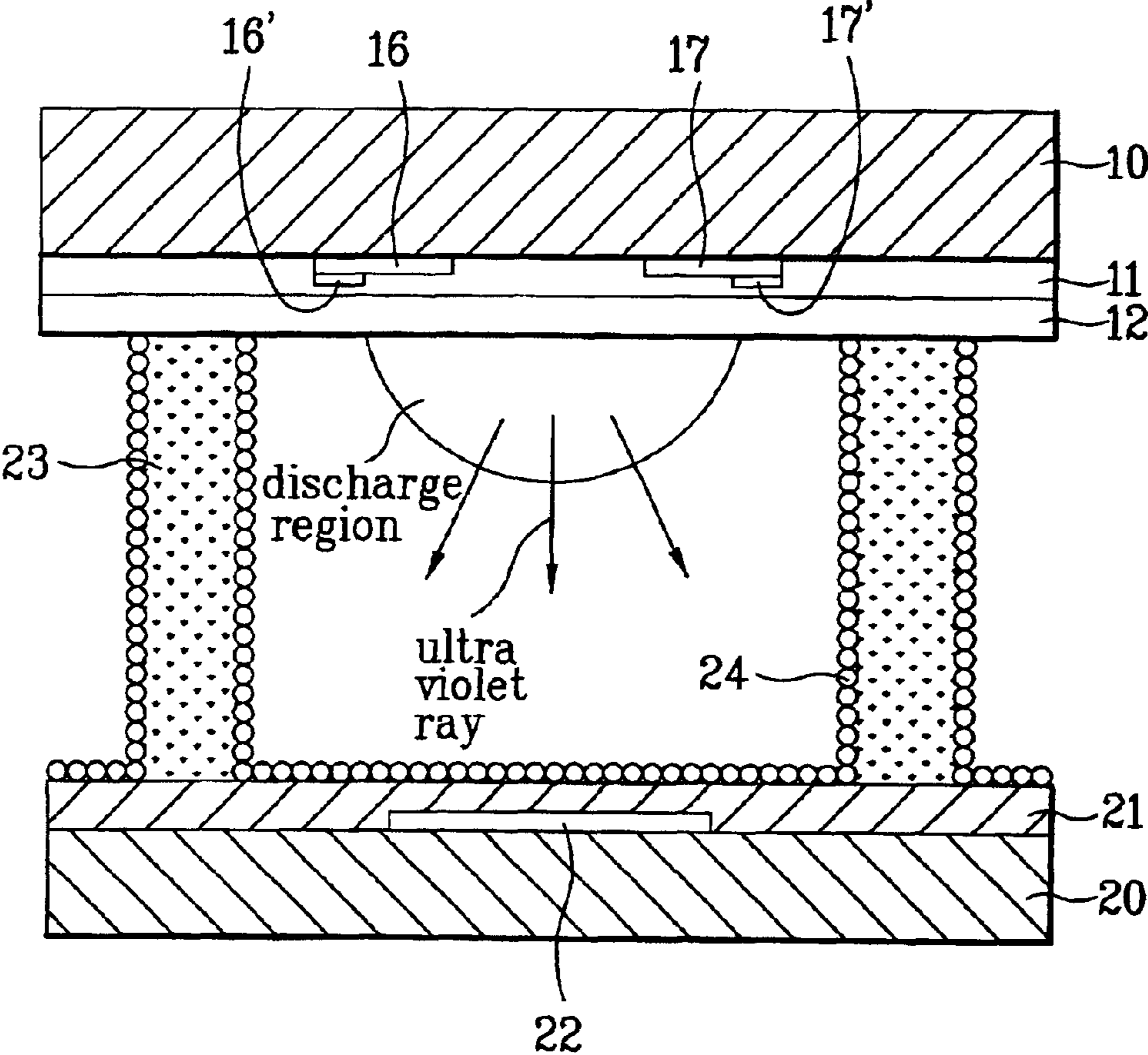


FIG. 2A
Related Art

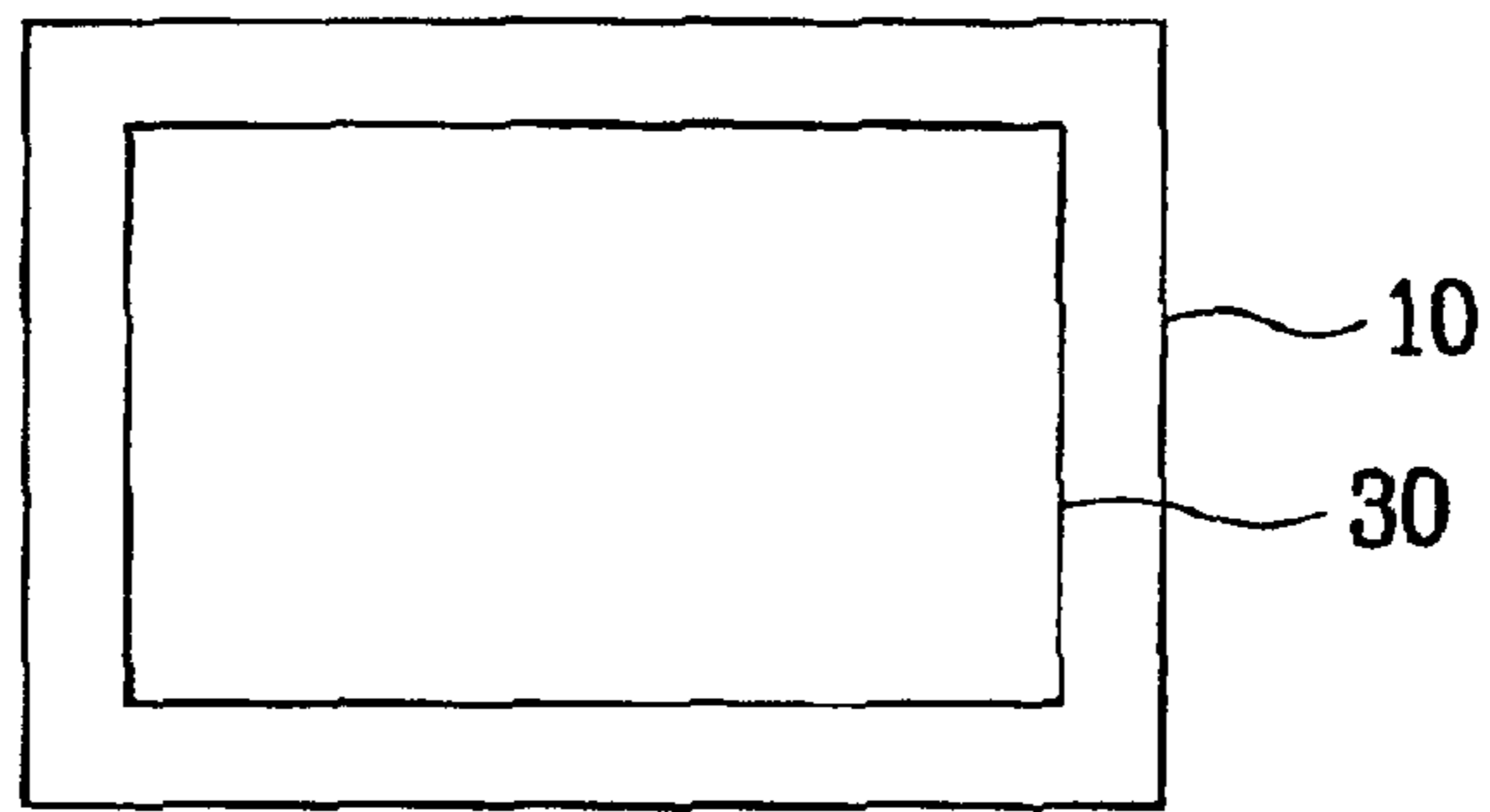
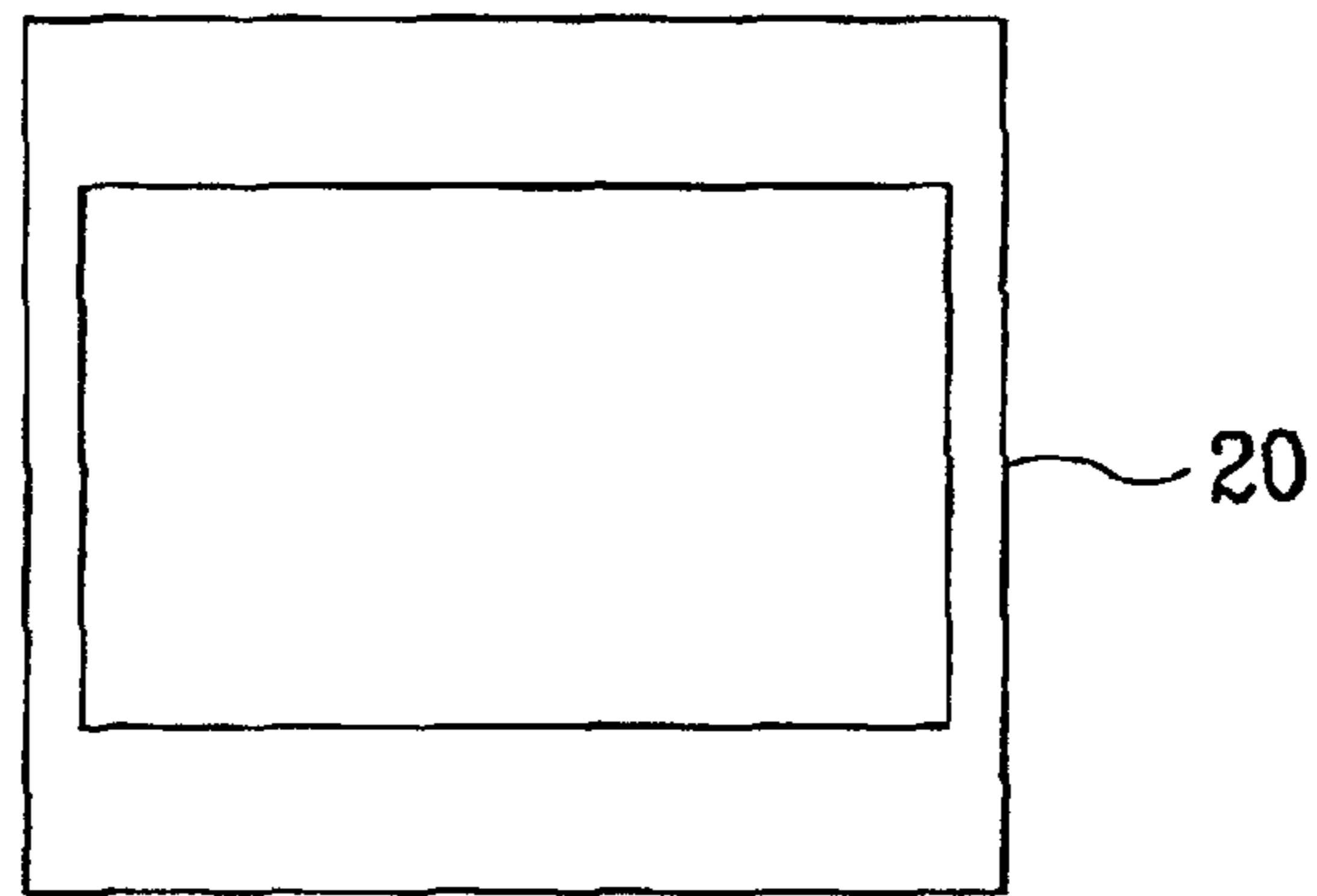


FIG. 2B
Related Art

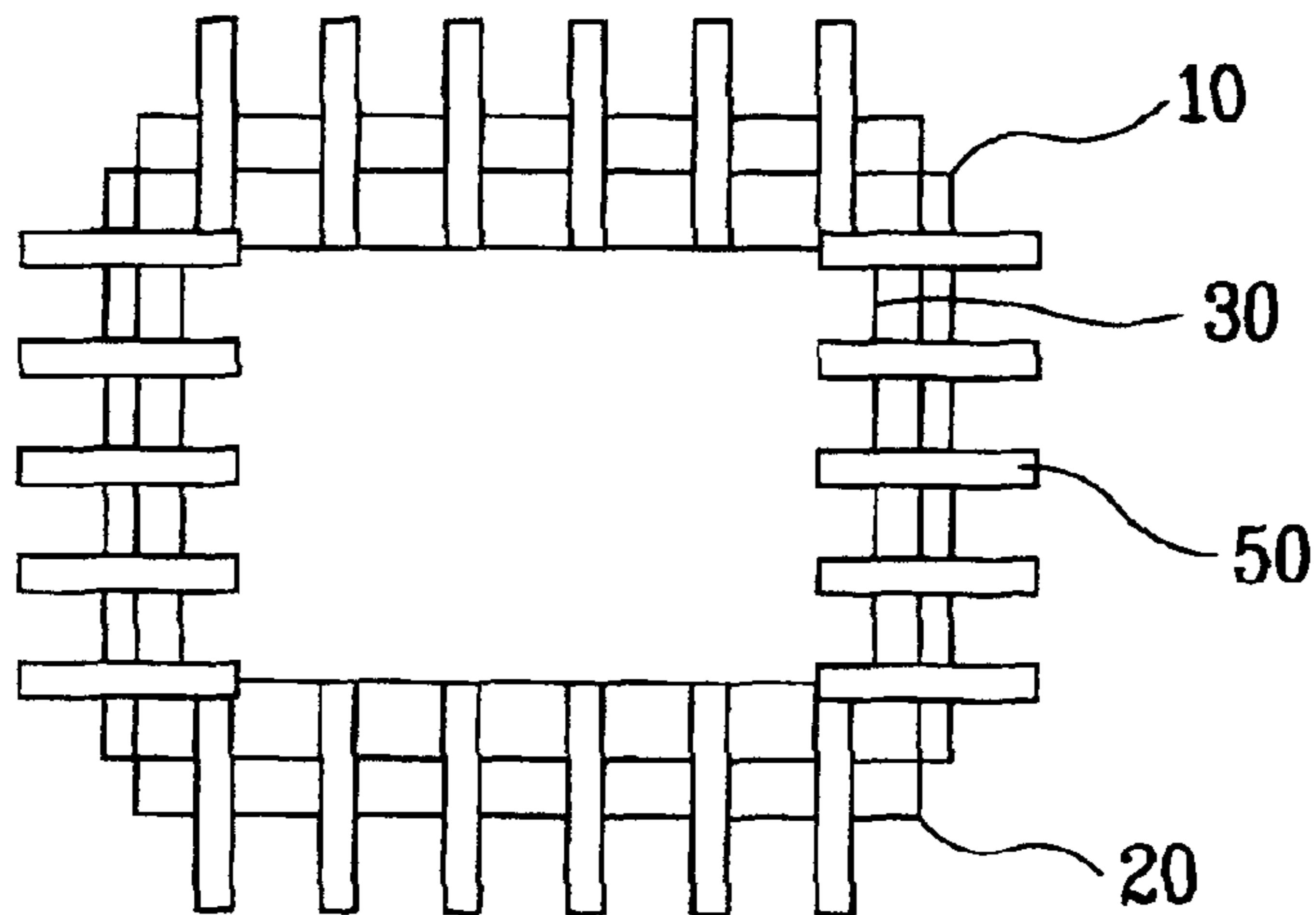


FIG. 2C
Related Art

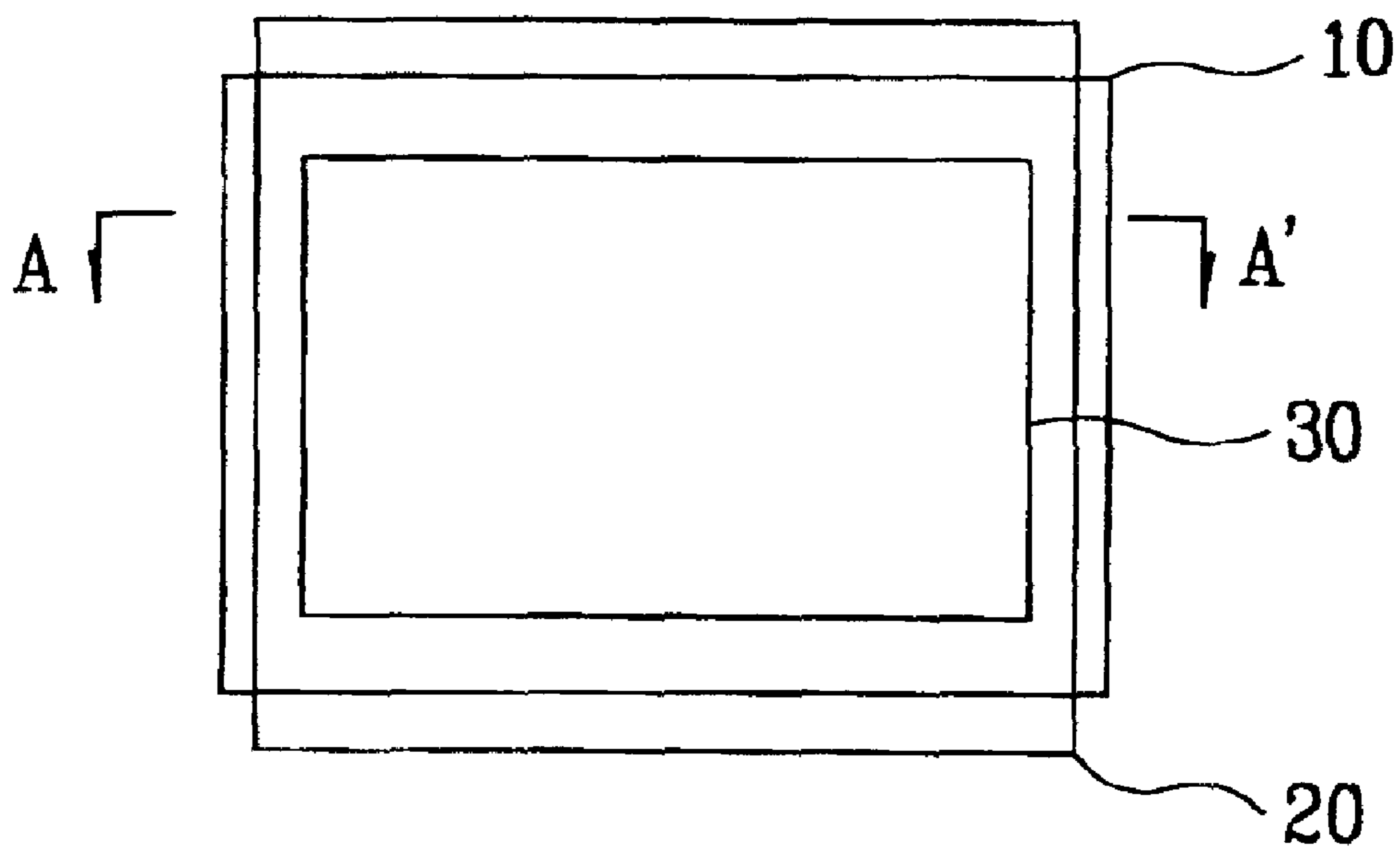


FIG. 2D
Related Art

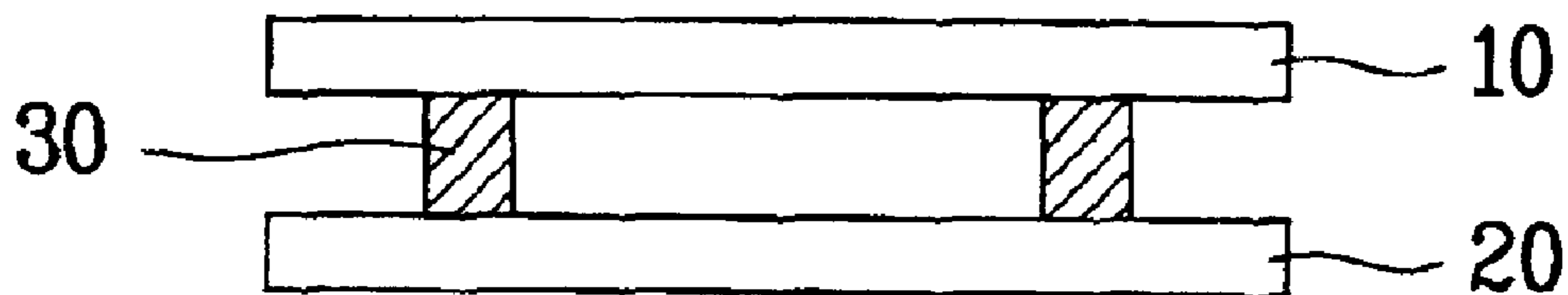


FIG. 3A

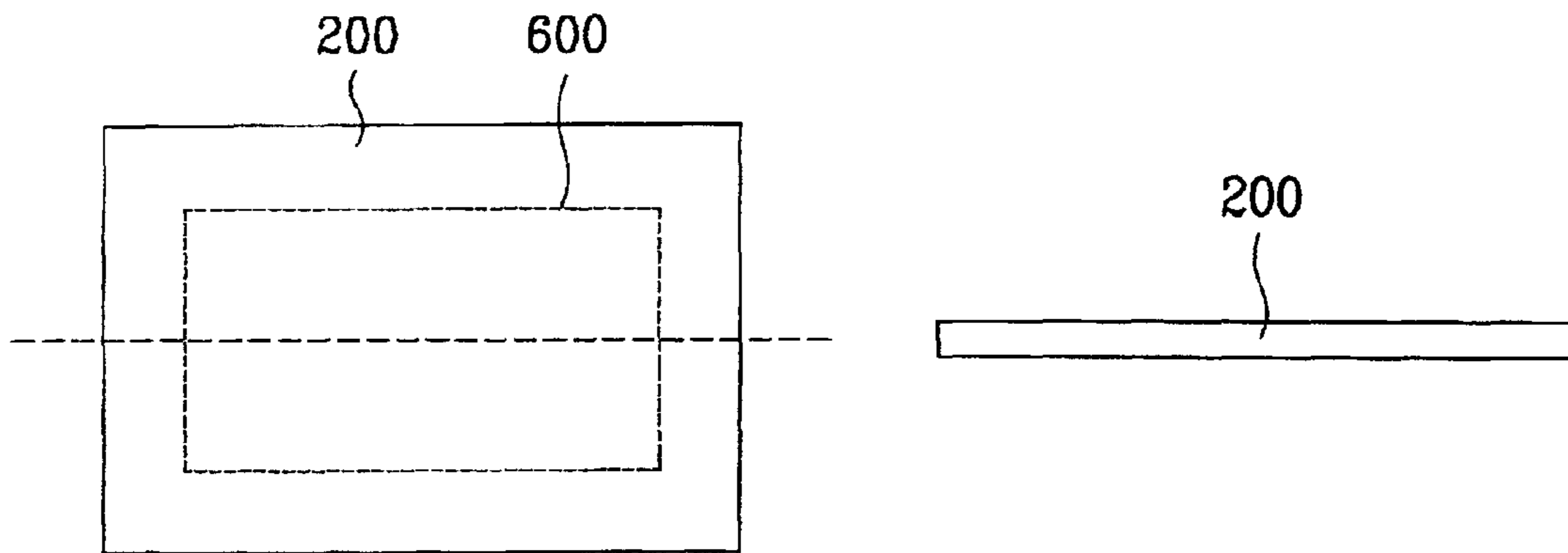


FIG. 3B

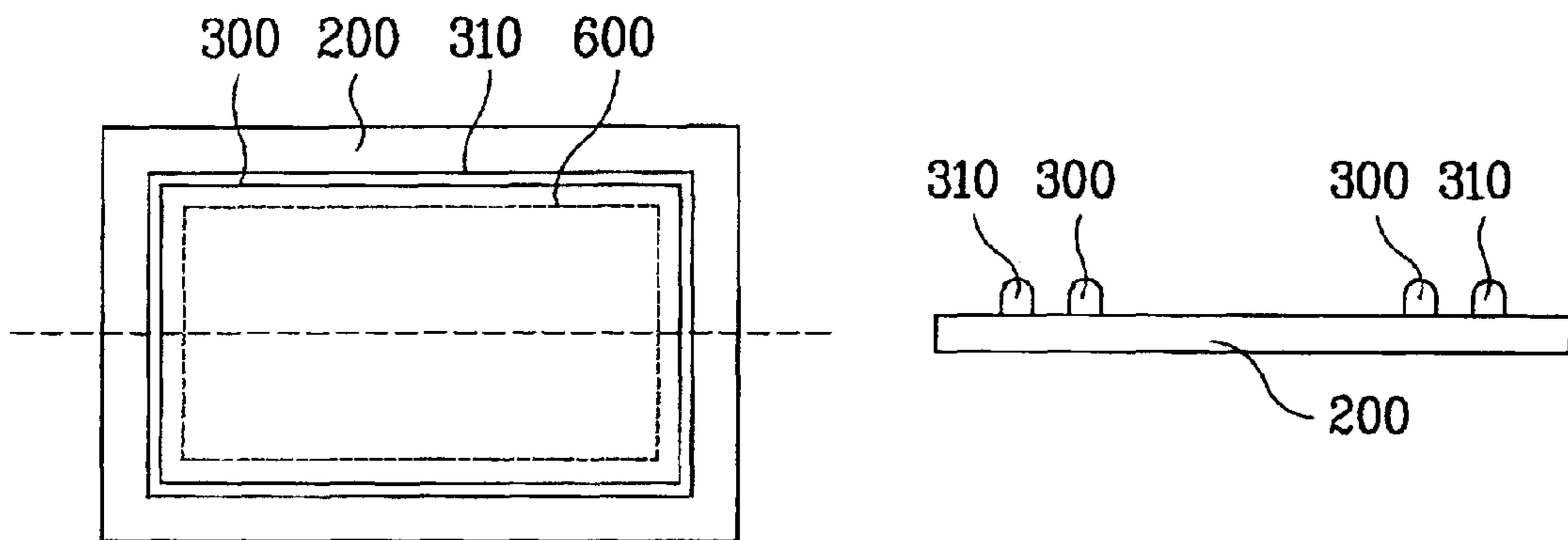


FIG. 3C

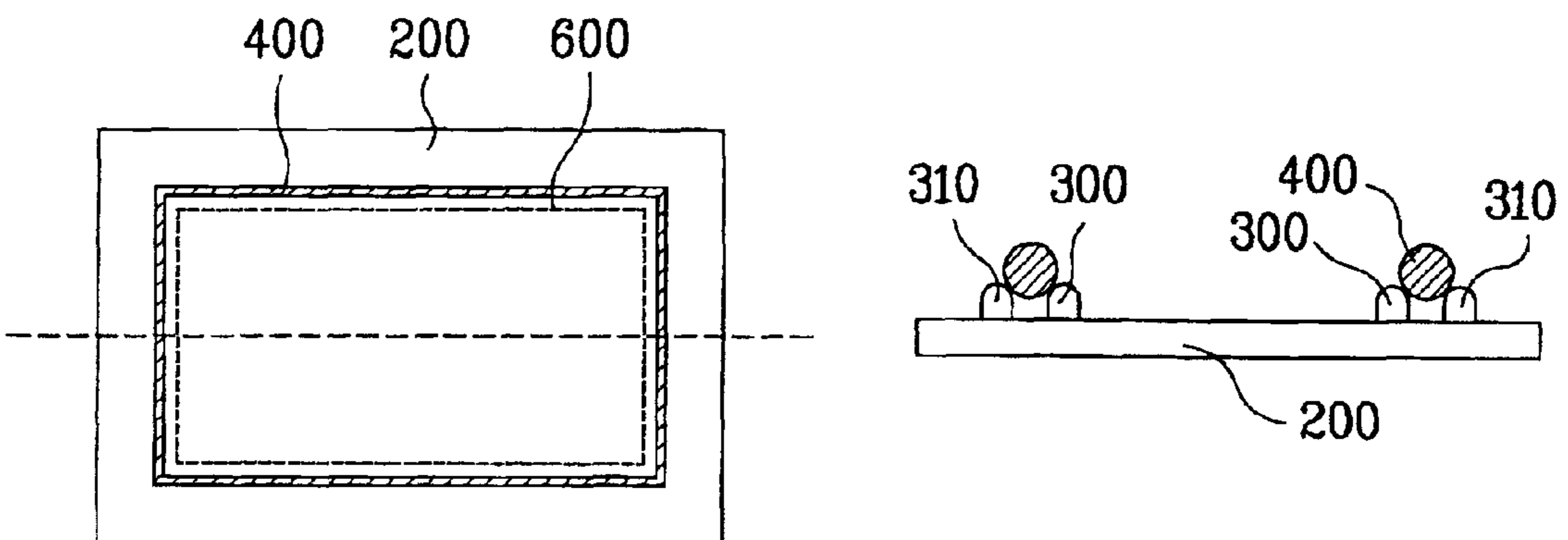


FIG. 3D

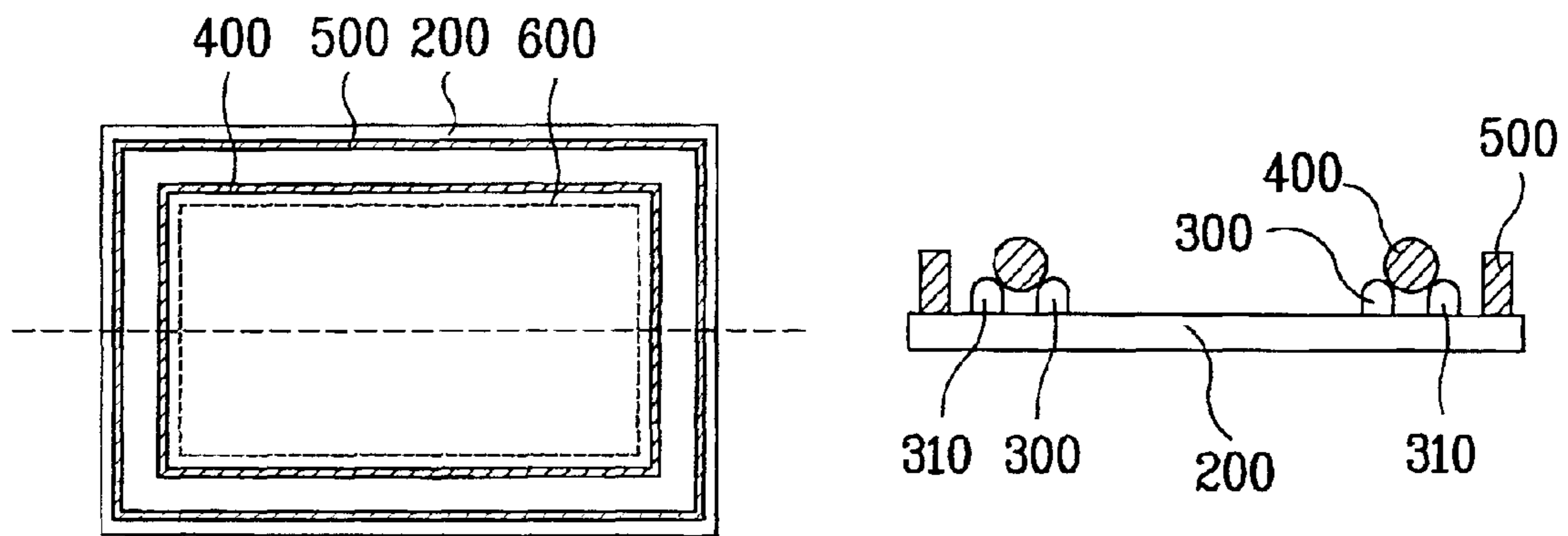
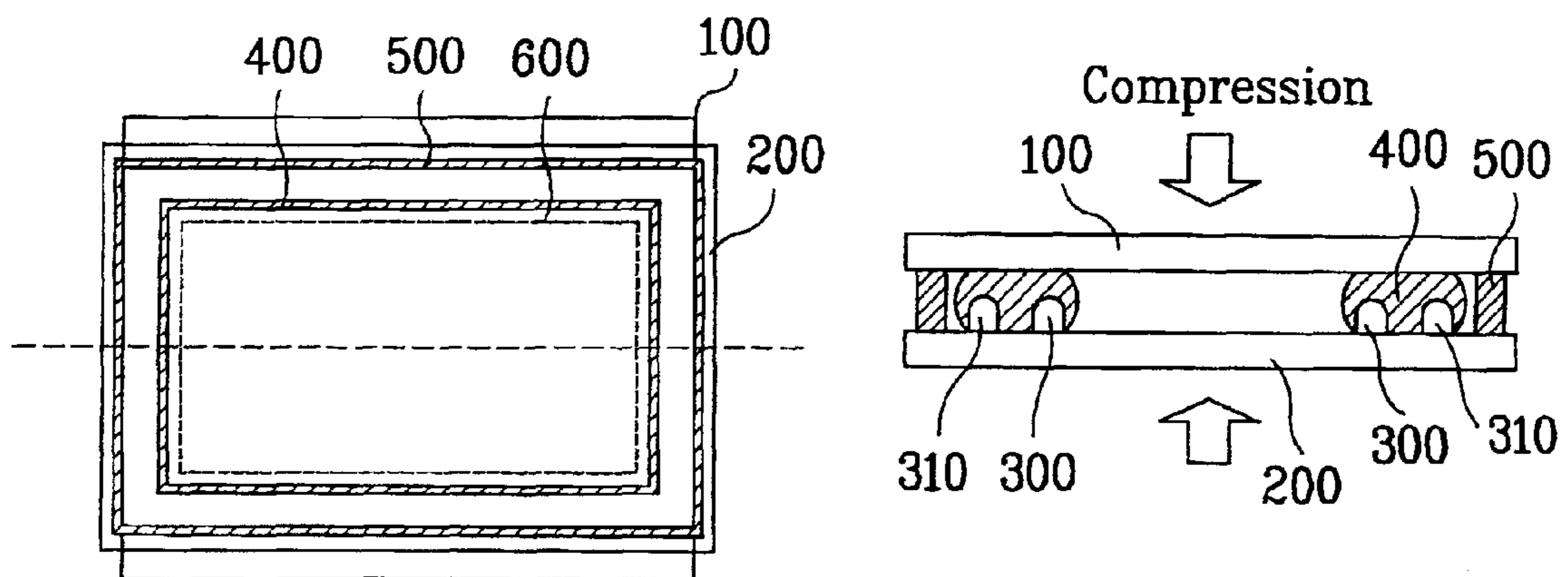


FIG. 3E



PLASMA DISPLAY PANEL AND METHOD FOR FABRICATING THE SAME

This application claims the benefit of the Korean Appli-
cation No. P2000-71689 filed on Nov. 29, 2000, which is
hereby incorporated by reference.

BACKGROUND OF THE INVENTION

1. Field of the Invention

The present invention relates to a plasma display panel,
and more particularly, to a plasma display panel and a
method for fabricating the same.

2. Discussion of the Related Art

In accordance with the advent of the multimedia era, a
display device that can display a natural color has been
required. Particularly, a plasma display panel has lately
attracted considerable attention an advanced display device
because a current cathode ray tube (CRT) or a liquid crystal
display (LCD) has limitations in realizing a large sized
display of 40 inch or greater.

A typical plasma display panel, as shown in FIGS. 1A and
1B, includes an upper substrate **10** and a lower substrate **20**
which face each other. FIG. 1C illustrates a sectional struc-
ture of the plasma display panel, in which the lower sub-
strate **20** is rotated by 90° for the convenience.

The upper substrate **10** includes scan electrodes **16** and
16', sustain electrodes **17** and **17'**, a dielectric layer **11**, and
a passivation layer **12**. The scan electrodes **16** and **16'** are
formed in parallel to the sustain electrodes **17** and **17'**. The
dielectric layer **11** and the passivation layer **12** are sequen-
tially formed on the upper substrate **10** including the scan
electrodes **16** and **16'** and the sustain electrodes **17** and **17'**.

The lower substrate **20** includes address electrodes **22**, a
dielectric layer **21**, barriers **23**, and a phosphor **24**. The
dielectric layer **21** is formed on an entire surface of the lower
substrate including the address electrodes **22**. The barriers
23 are formed on the dielectric layer **21** between the respec-
tive address electrodes **22**. The phosphor **24** is formed on
surfaces of the barriers **23** and the dielectric layer **21** in each
discharge cell.

Inert gases such as He and Xe are mixed in a space
between the upper substrate **10** and the lower substrate **20**.
The space forms a discharge area.

The operation of the aforementioned plasma display panel
will now be described.

If a driving voltage is applied between each address
electrode and each scan electrode, opposite discharge occurs
between the address electrode **22** and the scan electrodes **16**
and **16'**. Some electrons emitted from the inert gas within the
discharge cell come into collision with a surface of the
passivation layer due to the opposite discharge. The collision
of the electrons secondarily emits electrons from the surface
of the passivation layer. The secondarily emitted electrons
come into collision with a plasma gas to diffuse the dis-
charge. If the opposite discharge between the address elec-
trode **22** and the scan electrode **16** and **16'** ends, wall charges
having opposite polarities occur on the surface of the
passivation layer on the respective address and scan elec-
trodes.

If the discharge voltages having opposite polarities are
continuously applied to the scan electrodes **16** and **16'** and
the sustain electrodes **17** and **17'** and at the same time the
driving voltage applied to the address electrode **22** is cut off,
area discharge occurs in a discharge area on the surfaces of
the dielectric layer and the passivation layer due to the

potential difference between the scan electrodes **16** and **16'**
and the sustain electrodes **17** and **17'**. The electrons in the
discharge cell come into collision with the inert gas in the
discharge cell due to the opposite discharge and the area
discharge. As a result, the inert gas in the discharge cell is
excited and ultraviolet rays having a wavelength of 147 nm
occur in the discharge cell. The ultraviolet rays come into
collision with the phosphors surrounding the address elec-
trode and the barriers, so that the ultraviolet rays are emitted,
thereby displaying a picture image.

Therefore, to obtain an improved performance and a
longer life span, the plasma display panel should have rigid
internal films and no mixed gases except for the discharge
gases.

A method for fabricating the aforementioned plasma
display panel includes three fabricating processes such as a
prior process, a later process, and a module process.

In the prior process, various films are formed in the upper
and lower substrates **10** and **20**. In the later process, attach-
ment of the upper and lower substrates **10** and **20**, exhaust,
injection of a discharge gas, tip-off, aging, and test are
implemented. The tip-off is implemented in such a manner
that exhaust and injection of a discharge gas are imple-
mented through an exhaust pipe and then the exhaust gas is
cut and sealed. The aging is to apply a power source to an
electrode, drive the panel for a predetermined time, and
finally remove impurities, thereby obtaining a discharge
voltage drop effect.

Finally, in the module process, a circuit is mounted and
assembled to complete the plasma display panel.

The method for fabricating the related art plasma display
panel will now be described with reference to FIGS. 2A to
2C.

As shown in FIGS. 2A to 2C, the upper and lower
substrates **10** and **20** are fed to the attachment equipment,
and a sealant **30**, i.e., frit is deposited along a boundary of
the upper or lower substrate using a dispenser. The frit
consists of glass, SiO₂, and an additive for improving
adhesion.

The upper and lower substrates are dried at a temperature
of about 120° C. and fired at a high temperature of 400° C.
or greater to remove the impurities remaining in the frit.

The fired upper and lower substrates are fed to the
attachment equipment in a state that the upper substrate **10**
is exposed to the air.

As shown in FIG. 2B, the upper substrate **10** and the lower
substrate **20** are aligned in the attachment equipment and
then fixed by a nipper **50** for attachment. Then, the frit is
fused, so that the upper substrate **10** and the lower substrate
20 are attached to each other as shown in FIG. 2C.

Also, a long straw shaped exhaust pipe **40** of glass is
attached to an exhaust hole (not shown) of the lower
substrate **20** using a frit ring (not shown) during the attach-
ment process.

Next, the attached substrates are fed to an exhaust and gas
injection equipment. The exhaust and gas injection equip-
ment exhausts out mixtures stuck to the film and mixed
gases generated in the film using the exhaust pipe **40** under
high vacuum and heating conditions.

The discharge gas is injected through the exhaust gas **40**
and heat is applied to the end of the exhaust gas **40** so as not
to leak the injected discharge gas, thereby melting the end of
the exhaust gas **40** to implement the tip-off process.

Then, the aging is carried out and then the status of the
panel is tested. Thus, the process of fabricating the plasma
display panel is completed.

As described above, in the exhaust pipe type fabrication equipment, a separate type fabrication equipment separately carries out the attachment process, the exhaust process, and the gas injection process. The separate type fabrication equipment includes an attachment equipment and an exhaust and gas injection equipment. The exhaust and gas injection equipment includes a hot blast furnace (not shown) for forming exhaust and discharge gas injection conditions, and a cart (not shown) for loading a panel (not shown), carrying out exhaust and discharge gas injection within the hot blast furnace, and unloading the panel.

The cart has a complex structure that includes a vacuum pump (not shown) putting the panel under vacuum state, a vacuum pipe system consisting of an exhaust manifold (not shown), a valve and a pipe arrangement, a discharge gas injection bombe (not shown), a gas injection pipe system consisting of a gas injection manifold (not shown), a valve and a pipe arrangement, and a tip-off unit (not shown) for implementing tip-off of the exhaust pipe **40**.

However, the method for fabricating the related art plasma display panel has several problems.

First, the firing process carried out to remove impurities of the frit increases power consumption due to its heating and cooling functions. Also, since a large quantity of impurities are generated from the frit due to high heat applied during the attachment process, the exhaust time increases. Further, since the frit is susceptible to external impact, crack of the panel is caused during the external impact.

Moreover, since high heat is applied under high vacuum state during the attachment process, high load is applied to the panel made of glass fragile to thermal deviation and tensile strength, thereby damaging the panel and reducing characteristic of the panel.

SUMMARY OF THE INVENTION

Accordingly, the present invention is directed to a plasma display panel and a method for fabricating the same that substantially obviates one or more problems due to limitations and disadvantages of the related art.

An object of the present invention is to provide a plasma display panel and a method for fabricating the same in which an attachment process is carried out at a room temperature so as not to generate mixed gases, thereby reducing the fabricating process time of the plasma display panel and preventing characteristic and performance of the panel from being reduced and also preventing the panel from being damaged.

Another object of the present invention is to provide a plasma display panel and a method for fabricating the same in which a panel structure is not changed by external pressure variation.

Additional advantages, objects, and features of the invention will be set forth in part in the description which follows and in part will become apparent to those having ordinary skill in the art upon examination of the following or may be learned from practice of the invention. The objectives and other advantages of the invention may be realized and attained by the structure particularly pointed out in the written description and claims hereof as well as the appended drawings.

To achieve these objects and other advantages and in accordance with the purpose of the invention, as embodied and broadly described herein, a plasma display panel includes: a first substrate; a first adhesive deposited along a predetermined area outside an active picture of a first

substrate; a second adhesive deposited outside a portion where the first adhesive is deposited, to have a predetermined interval from the first adhesive; a sealant deposited to align with upper portions of the first and second adhesives; an adhesive deposited outside a portion where the second adhesive is deposited, to have a predetermined interval from the second adhesive; and a second substrate aligned on the first substrate in a state where it is adhered to surfaces of the sealant and the adhesive.

In another aspect of the present invention, a method for fabricating a plasma display panel includes the steps of: depositing a first adhesive along a predetermined area outside an active picture of a first substrate; depositing a second adhesive outside a portion where the first adhesive is deposited, to have a predetermined interval from the first adhesive; depositing a sealant to align with upper portions of the first and second adhesives; depositing an adhesive outside a portion where the second adhesive is deposited, to have a predetermined interval from the second adhesive; aligning a second substrate on the first substrate; and attaching the first and second substrates to each other under a predetermined pressure.

It is to be understood that both the foregoing general description and the following detailed description of the present invention are exemplary and explanatory and are intended to provide further explanation of the invention as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

The accompanying drawings, which are included to provide a further understanding of the invention and are incorporated in and constitute a part of this application, illustrate embodiment(s) of the invention and together with the description serve to explain the principle of the invention. In the drawings:

FIG. 1A is a plane view illustrating a structure of a typical plasma display panel;

FIGS. 1B and 1C are perspective views illustrating a structure of a typical plasma display panel;

FIGS. 2A to 2D are sectional views illustrating an attachment process of a related art plasma display panel; and

FIGS. 3A to 3E are sectional views illustrating a process of fabricating a plasma display panel according to the present invention.

DETAILED DESCRIPTION OF THE INVENTION

Reference will now be made in detail to the preferred embodiments of the present invention, examples of which are illustrated in the accompanying drawings. Wherever possible, the same reference numbers will be used throughout the drawings to refer to the same or like parts.

A process of fabricating a plasma display panel will be described with reference to FIGS. 3A to 3E.

A rib is formed on a lower substrate **200** of FIG. 3A using first and second adhesives **300** and **310** by a screen printing method used when forming barriers. In other words, the first adhesive **300** is deposited along a predetermined region outside an active picture of the lower substrate **200**, and then the second adhesive **310** is deposited, at a predetermined interval from the first adhesive, outside a portion where the first adhesive **300** is deposited.

The first and second adhesives **300** and **310** are made of the same material as each other and are not deformed by pressure applied when the upper substrate **100** and the lower

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substrate **200** are attached to each other. The first and second adhesives **300** and **310** should be lower than the barriers.

As shown in FIG. 3C, a sealant **400** is deposited to align with upper portions of the first and second adhesives **300** and **310** deposited on the lower substrate **200**. The sealant **400** is made of an elastomer based material having a characteristic deformed by attachment pressure.

At this time, the elastomer based sealant **400** is of a rubber material unlike frit which is the existing sealant. The sealant **400** has characteristics having no mixed gas exhausted according to heating or pressurization and constant resiliency that can endure external impact.

As shown in FIG. 3D, an adhesive **500** is deposited at a predetermined interval along an outer wall of the second adhesive **310** deposited on the lower substrate **200**. The adhesive **500** is an auxiliary pressure applying means that attaches the upper substrate **100** to the lower substrate **200**. Also, the adhesive **500** can be congealed quickly at a room temperature and can pressurize the sealant **400**. A material that can endure condensation/tension is used as the adhesive **500**.

Subsequently, as shown in FIG. 3E, the upper substrate **100** and the lower substrate **200** are precisely aligned with each other and then attached to each other by a predetermined pressure.

The attachment of the upper and lower substrates **100** and **200** is completed as the adhesive **500** is congealed.

In other words, the barriers are formed in the upper and lower substrates **100** and **200** using the adhesive when the upper substrate **100** is attached to the lower substrate **200**. Accordingly, the elastomer based sealant **400** can be aligned desirably by the barriers and is deformed by the attachment pressure to obtain an improved vacuum effect and provide a structural supporting power in response to a pressure difference between the inside of the panel and its outside, thereby preventing any deformation of the panel from occurring.

Furthermore, since the fabricating and attachment processes according to the present invention are carried out at a room temperature, heating and cooling processes are not required after the upper substrate **100** is attached to the lower substrate **200** by fusing the frit, unlike the related art. Accordingly, energy loss can be avoided and the process time can be reduced.

The plasma display panel according to the present invention includes a first substrate **200**, a first adhesive **300** deposited along a predetermined area outside an active picture of the first substrate **200**, a second adhesive **310** deposited outside a portion where the first adhesive **300** is deposited, to have a predetermined interval from the first adhesive **300**, a sealant **400** deposited to align with upper portions of the first and second adhesives **300** and **310**, an adhesive **500** deposited outside a portion where the second adhesive **310** is deposited, to have a predetermined interval from the second adhesive **310**, and a second substrate **100** aligned above the first substrate **200** in a state where it is adhered to surfaces of the sealant **400** and the adhesive **500**.

The method for fabricating the plasma display panel according to the present invention has the following advantages.

First, since the upper substrate is attached to the lower substrate at a room temperature, load applied to the panel is small so that characteristic of the panel can be prevented from being deteriorated, unlike the related art high temperature/high pressure conditions. Also, heating and cooling processes are not required, thereby minimizing energy loss.

Furthermore, since an elastomer based rubber is used as the sealant instead of a glass based sealant, mixed gases are

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not generated, thereby preventing the characteristic of the panel from being deteriorated and also preventing the panel from being damaged.

Finally, since the barriers are formed to align the elastomer of the lower substrate and generate the structural supporting power, the sealing power due to vacuum can be improved, and sliding between the adhesive and the glass substrate can be avoided when the upper substrate and the lower substrate are attached to each other, thereby enabling a structural position alignment.

It will be apparent to those skilled in the art than various modifications and variations can be made in the present invention. Thus, it is intended that the present invention covers the modifications and variations of this invention provided they come within the scope of the appended claims and their equivalents.

What is claimed is:

1. A method for fabricating a plasma display panel comprising:

depositing a first adhesive along a predetermined area outside an active picture of a first substrate;

depositing a second adhesive outside a portion where the first adhesive is deposited, to have a predetermined interval from the first adhesive;

depositing a sealant to align with upper portions of the first and second adhesives;

depositing a third adhesive outside a portion where the second adhesive is deposited, to have a predetermined interval from the second adhesive;

aligning a second substrate on the first substrate; and

attaching the first and second substrates to each other via the sealant and the third adhesive, under a predetermined pressure.

2. The method of claim 1, wherein the first and second adhesives are made of the same material as each other.

3. The method of claim 1, wherein the first and second adhesives are made of a material that is not deformed by an attachment pressure.

4. The method of claim 1, wherein the sealant is made of a material deformed by the attachment pressure.

5. The method of claim 1, wherein the sealant is an elastomer based material.

6. The method of claim 1, wherein all the steps are carried out at a room temperature.

7. A plasma display panel comprising:

a first substrate;

a first adhesive deposited along a predetermined area outside an active picture of a first substrate;

a second adhesive deposited outside a portion where the first adhesive is deposited, to have a predetermined interval from the first adhesive;

a sealant deposited to align with upper portions of the first and second adhesives;

a third adhesive deposited outside a portion where the second adhesive is deposited, to have a predetermined interval from the second adhesive; and

a second substrate aligned on the first substrate in a state where it is adhered to surfaces of the sealant and the third adhesive.

8. The plasma display panel of claim 7, wherein the first and second adhesives are made of the same material as each other.

9. The plasma display panel of claim 7, wherein the sealant is made of a material deformed by an attachment pressure.

10. The plasma display panel of claim 7, wherein the sealant is an elastomer based material.